Application No.: 09/891,535 Docket No.: 8733.459.00-US

## **AMENDMENTS TO THE CLAIMS**

- 1. (Currently Amended): A liquid crystal display device comprising:
  - a first substrate with a pixel area;
- a gate line on the first substrate, wherein the gate line includes an edge and a gate electrode;
  - an insulating layer over the gate line;
- a data line over the insulating layer, wherein the data line includes at least two conductive members;
- a short-prevention member on the insulating layer, <u>over</u> [[above]] the edge, and between the at least two conductive members; and
  - a pixel electrode in the pixel area;
- wherein the short-prevention member prevents electric shorts between the at least two conductive members caused by residual material that extends along the edge.
- 2. (Currently Amended): The liquid crystal display device of claim 1, wherein the gate line includes a gate electrode and a lower electrode of a storage capacitor.
- 3. (Previously Presented): The liquid crystal display device of claim 1, wherein the data line comprises a source electrode, a drain electrode and an upper electrode of a storage capacitor.
- 4. (Original): The liquid crystal display device of claim 1, wherein the insulating layer forms a gate insulating layer.
- 5. (Original): The liquid crystal display device of claim 4, further comprising:
  - a gate electrode under the gate insulating layer;
  - a semiconductor layer on the gate insulating layer and over the gate electrode; and source and drain electrodes over the semiconductor layer.
- 6. (Previously Presented): The liquid crystal display device of claim 5, wherein the short-prevention member is formed at a same time as the semiconductor layer.

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7. (Previously Presented): The liquid crystal display device of claim 5, wherein the short-prevention member is comprised of a same material as the semiconductor layer.

- 8. (Original): The liquid crystal display device of claim 1, further comprising: a lower electrode; and an upper electrode, wherein the lower electrode and the upper electrode are separated by the insulating layer.
- 9. (Original): The liquid crystal display device of claim 1, wherein the short-prevention member is formed as an island.
- 10. (Original): The liquid crystal display device of claim 1, further including:
  - a second substrate adjacent the first substrate; and
  - a liquid crystal between the first substrate and the second substrate.
- 11 -18 (Canceled).
- 19. (Currently Amended): A method of fabricating a liquid crystal display device, comprising:

forming a gate line on a first substrate having a pixel area, the gate line including a gate electrode;

forming an insulating layer over the first substrate and over the gate line;

forming a short-prevention member on the insulating layer and over an edge of the gate line;

forming a data line on the insulating layer; and

forming a pixel electrode in the pixel area;

wherein the short-prevention member is disposed to prevent electric shorts in the data line.

20. (Currently Amended): The method of claim 19, wherein the gate line is formed using a wet etch process, and wherein the gate line includes a gate electrode, and a lower electrode of a storage capacitor.

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21. (Previously Presented): The method of claim 19, wherein the data line is formed using a wet etch process, and wherein the data line includes source/drain electrodes, and an upper electrode of a storage capacitor.

22. (Original): The method of claim 20, further comprising:

forming a gate electrode under the insulating layer; forming a semiconductor layer over the insulating layer; and forming source/drain electrodes over the semiconductor layer.

- 23. (Original): The method of claim 22, wherein the short-prevention member is formed of a same material as the semiconductor layer.
- 24. (Original): The method of claim 19, wherein the short-prevention member is formed as an island.
- 25. (Original): The method of claim 19, wherein the short-prevention layer is formed by dry etching.
- 26 -33 (Canceled).
- 34. (Previously Presented): The device of claim 2, wherein one of the short-prevention members is formed over an edge of the gate electrode.
- 35. (Previously Presented): The method of claim 20, wherein one of the short-prevention members is formed over an edge of the gate electrode.
- 36. (Withdrawn): The liquid crystal display device of claim 1, further comprising a second short-prevention member.
- 37. (Withdrawn): The liquid crystal display device of claim 19, further comprising a second short-term prevention member.

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